

**METHOD AND APPARATUS FOR ANGULAR-RESOLVED SPECTROSCOPIC
LITHOGRAPHY CHARACTERIZATION**

ABSTRACT

An apparatus and method to determine a property of a substrate by measuring, in the pupil plane of a high numerical aperture lens, an angle-resolved spectrum as a result of radiation being reflected off the substrate. The property may be angle and wavelength dependent and may include intensity of TM- and TE-polarized light and their relative phase difference.

(Figure 3)